

Supporting information

Multilevel Oxygen-vacancies Conductive Filaments in the β -Ga₂O₃ Based Resistive Random Access Memory

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Table S1. The defect formation energies of V_{Os} with different charge states at $E_F = 0$ eV under the O-rich condition in the β -Ga₂O₃ supercells with 120, 160, and 300 atoms.

supercell	0 charge state			+2 charge state		
	V_{O1}	V_{O2}	V_{O3}	V_{O1}	V_{O2}	V_{O3}
120 atoms	1.2967	0.3729	0.5083	3.6041	4.0112	4.2763
160 atoms	1.2944	0.3721	0.5064	3.6038	4.0093	4.2711
300 atoms	1.2950	0.3709	0.5073	3.6046	4.0106	4.2715

Supercells of 120, 160, and 300 atoms are employed to verify the convergence of defect formation energies. It can be seen from Table S1 that there is negligible difference (less than 0.01 eV) between the defect formation energies obtained in supercells of 120, 160, and 300 atoms, regardless of the position and charge state of V_O . Thus, the $1 \times 3 \times 2$ supercell of 120 atom is used to investigate the properties of defective β -Ga₂O₃.

Table S2. The defect formation energies (eV) of charged V_{OS} at different E_F (the value of E_F is listed in the parentheses) under the O-rich condition and Ga-rich condition.

	Under the O-rich condition			
	0	+1	+2	-3
V_{O1}	3.61 (2.26 eV)	3.41 (0 eV)	1.29 (0 eV)	
V_{O2}	4.03 (2.26 eV)	2.84 (0 eV)	0.37 (0 eV)	
V_{O3}	4.28 (2.26 eV)	2.93 (0 eV)	0.48 (0 eV)	
V_{Ga1}	4.85 (0 eV)			-0.84 (2.26 eV)
V_{Ga2}	5.23 (0 eV)			-1.15 (2.26 eV)
	Under the Ga-rich condition			
	0	+1	+2	-3
V_{O1}	0.50 (2.26 eV)	0.27 (0 eV)	-1.81 (0 eV)	
V_{O2}	0.92 (2.26 eV)	-0.28 (0 eV)	-2.74 (0 eV)	
V_{O3}	1.17 (2.26 eV)	-0.18 (0 eV)	-2.63 (0 eV)	
V_{Ga1}	9.51 (0 eV)			3.81 (2.26 eV)
V_{Ga2}	9.89 (0 eV)			3.99 (2.26 eV)

Table S3. The calculated Bader charge for neighboring Ga-atoms around different V_O in the β -Ga₂O₃ supercell.

	Pure β -Ga ₂ O ₃	Defective β -Ga ₂ O ₃ with V_O^0			Defective β -Ga ₂ O ₃ with V_O^{2+}		
		V_{O1}^0	V_{O2}^0	V_{O3}^0	V_{O1}^{2+}	V_{O2}^{2+}	V_{O3}^{2+}
Ga ₁	1.75 e	1.86 e	1.83 e	1.82 e	2.26 e	2.69 e	2.61 e
Ga ₂	1.68 e	1.78 e	1.73 e	1.73 e	2.21 e	2.49 e	2.47 e

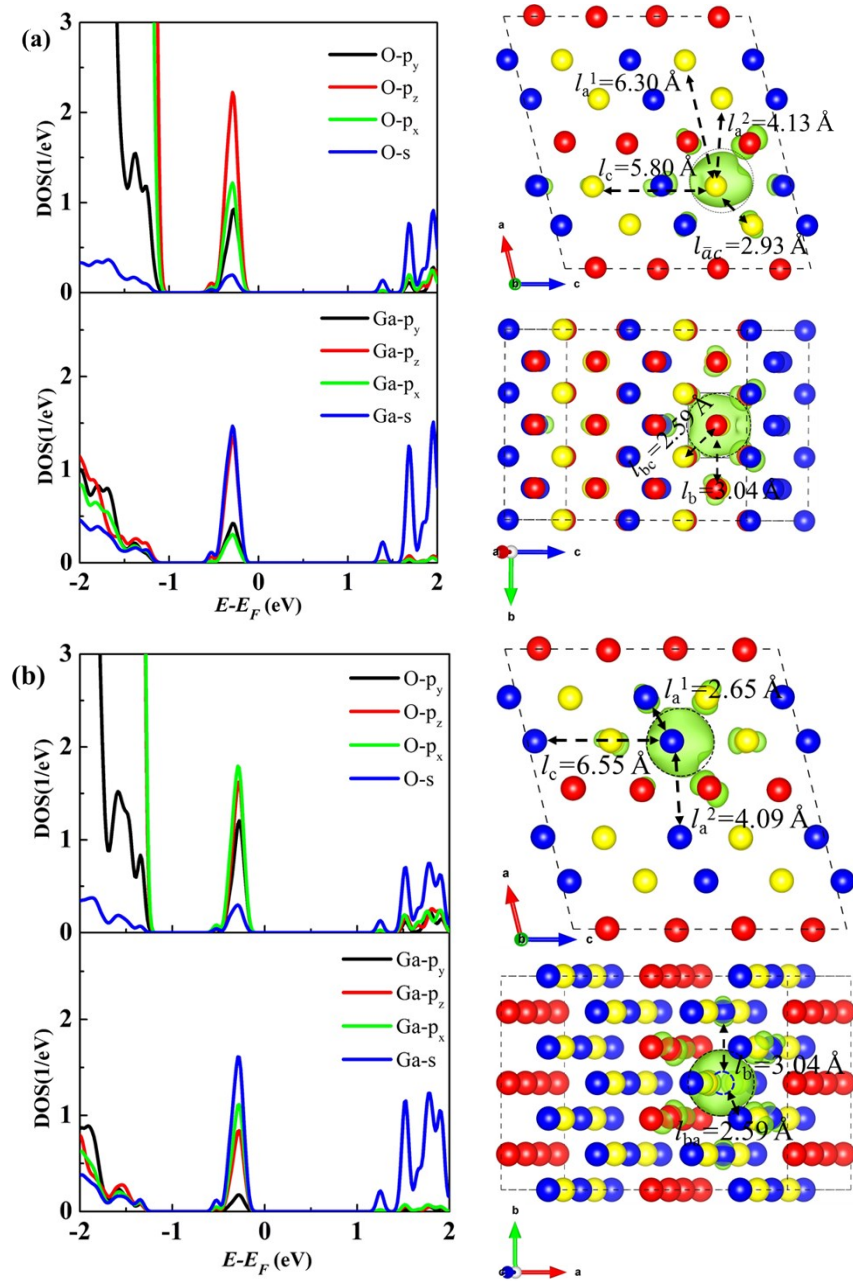


Figure S2. Density of states and charge density distributions of (a) V_{O2} and (b) V_{O3} in β - Ga_2O_3 , respectively. The marked l_a , l_b , and l_c are respective the distance between V_O and the O atom at its equivalent site along the a, b, and c direction.

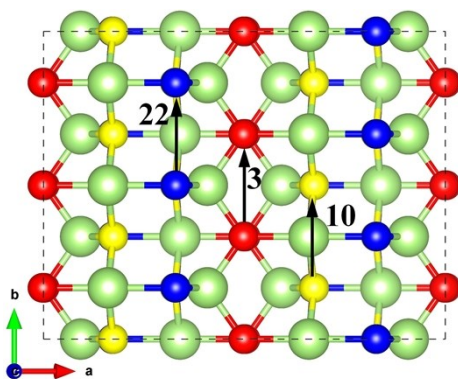


Figure S3. The migration pathways of O-vacancies along the b direction. The path 3, 10 and 22 are respective the migrations of V_{O1} , V_{O2} and V_{O3} , respectively.